

PREFACE

This thesis entitled “***In-Situ Growth of Metal and Metal Sulfide Nanoparticles within Solution Processed TiO₂ Thin Film for Photodetection and Energy Harvesting Applications***” is mainly focused on the new technique to grow metal or metal sulfide nanoparticle within TiO₂ thin film by a low-cost solution-processed technique. These *in-situ* grown metal/TiO₂ or metal sulfide/TiO₂ heterojunction nanocomposite thin films have been utilized for photoelectrochemical hydrogen generation and photodetector fabrication. For this synthesis, initially Li₄Ti₅O₁₂, a popular ion-conducting metal oxide (ICMO) has been synthesis in a sol-gel technique. Due to the ion-conducting nature of this ceramic thin film, Li-ion can move through the crystal channel. Taking advantage of this feature, Li⁺ of this ceramic film has been exchanged with Ag⁺ or Cu⁺ by an ion-exchange process that forms Ag₄Ti₅O₁₂ and Cu₄Ti₅O₁₂ respectively, after ion-exchange. For metal/TiO₂ heterojunctions, these ion-exchange thin films have been reduced by NaBH₄ solution. On the other hand, for metal sulfide/TiO₂ heterojunctions formation, those ion-exchanged thin films have been dipped inside Na₂S solution to grow the metal sulfide nanoparticle inside TiO₂. This typical growth technique of nanoparticle allows us to fabricated metal/TiO₂ or metal sulfide/TiO₂ heterojunction with a very low interface trap state that enables us to utilize this thin film for efficient photoelectrochemical H₂ generation and efficient Vis-NIR photodetector fabrication.

So far, photoelectrocatalytic H₂ generation by metal/TiO₂ or metal sulfide/TiO₂ heterojunctions photoanode is very poor. Because its efficiency strongly depends on the nature of metal or metal chalcogenide/TiO₂ interfaces. In most of those studies, metal or

metal chalcogenide NPs are deposited on top of TiO₂ surfaces that make poor interfaces exhibiting significant interface trap states. An ideal metal/metal oxide or metal chalcogenide/metal oxide heterogeneous photocatalysis requires a large interface with very low trap states to reach efficient charge transfer without significant recombination at the interfacial. Therefore, a better synthesis technique providing the formation of heterojunction with less interfacial trap states is needed to achieve, which can certainly improve the catalytic performance useful for different industrial applications.

Important Finding of the Present Work:

1) A noble synthesis method for metal/TiO₂ or metal sulfide/TiO₂ heterojunctions thin film

As mention earlier, in our present study, a unique approach has been adopted to develop an **in-situ** growth technique to form metal (Ag, Au, or Cu), and metal sulfide (M₂S, M = Ag, Cu), Cu₂S, and Ag₂S NPs within solution-processed TiO₂ thin film. This heterojunction thin-film fabrication has been performed in three simple consecutive steps. In the first step, sol-gel derived **Li₄Ti₅O₁₂** thin film has been fabricated by dip-coating method. In the second step, the ion-exchange process replaced the Li⁺ by either Ag⁺ or Cu⁺. Finally, reduction or sulfurization process converted Ag⁺ (or Cu⁺) to Ag-NP (Cu NP) or Ag₂S (or Cu₂S-NP). Utilizing this technique, the large area Ag-TiO₂, Ag₂S-TiO₂, and Cu₂S-TiO₂ thin film devices have been fabricated and characterized thoroughly for fundamental properties.

2) Metal/TiO₂ or metal sulfide/TiO₂ heterojunctions thin film for efficient photoelectrochemical H₂ generation.

Three different heterojunction thin films have been fabricated including Ag/TiO₂, Ag₂S-TiO₂, and Cu₂S/TiO₂ which have been grown on a transparent conducting substrate. Again each type of heterojunction thin film was grown on three different conducting substrates, including fluorine-doped tin oxide (FTO), FTO/TiO₂ (sol-gel), and FTO/TiO₂ (NPs) coated glass. A comparative photo-electrocatalytic measurement has been done for each heterojunction films that shows that photoanodes on FTO/TiO₂ (NPs) coated glass generate highest photocurrent density ~42, 50 and 36 mA cm⁻² respectively at 0.5 V vs. NHE in 1M KOH solution which is three orders higher than pure TiO₂ and stable for more than 1.5 hours, indicating their excellent potential application for photoelectrochemical (PEC) water splitting.

3) Metal sulfide/ TiO₂ heterojunctions thin film for broadband photodetection

A Cu₂S/TiO₂ heterojunction thin film was fabricated on a glass substrate exactly in the same method as mention earlier. This process allows us to fabricate smooth and large area TiO₂ thin film containing Cu₂S NPs with an average particle size of 10.5 nm. A visible light lateral photodetector has been fabricated based on this Cu₂S-TiO₂ thin film that shows a very good photoresponsivity. For better sensitivity device has been fabricated with ZnO underlying layer with a device architecture Al/Cu₂S-TiO₂/ZnO/glass. This lateral heterojunction photodetector shows a detectivity of 1.7×10^{11} jones.

A list of journals and books used to bind up the thesis has been given at the end of the thesis as references.